

*Amendments to the Claims*

1-3. (Canceled)

4. (Currently Amended) A method of etching and cleaning objects contained in a vessel, comprising the steps of:  
etching the objects by providing etching solution into the vessel;  
forcing out ~~exiting~~ the etching solution ~~alone~~ from the vessel by providing pressurized gas into the vessel;  
cleaning the objects by providing cleaning solution into the vessel; and  
draining the cleaning solution from the vessel.

5. (Currently Amended) The method of claim 4, wherein the sequential steps of forcing out the etching solution alone and draining the cleaning solution and exiting etching solution are carried out processed through different draining pipes connected to the vessel.

6. (Original) The method of claim 4, wherein the pressurized gas is nitrogen gas.

7. (Original) The method of claim 4, wherein the etching solution is Oxalic acid solution or diluted Oxalic acid solution.

8. (Original) The method of claim 4, wherein the cleaning solution is deionized water.

9. (Currently Amended) The method of claim 4, wherein ~~the step of forcing out~~ exiting the etching solution is ~~enhanced done with~~ by pumping the etching solution out of the vessel.

10. (Currently Amended) The method of claim 4, further comprising;  
drying the objects by providing drying gas into the vessel after draining the cleaning solution.

11. (Currently Amended) The method of claim 10, wherein the drying gas includes ~~isopropyl alcohol IPA~~.